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Permalink https://escholarship.org/uc/item/12h0652w

Journal Organometallics, 30(17)

ISSN 0276-7333

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Publication Date 2011-09-12

DOI 10.1021/om200636u

Peer reviewed

ORGANOMETALLICS

Triethylsilyl Perfluoro-Tetraphenylborate, [Et₃Si⁺][F₂₀-BPh₄⁻], a Widely Used Nonexistent Compound

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Supporting Information

ABSTRACT: The commonly used triethylsilyl perfluoro-tetraphenylborate salt, $[Et_3Si^+][F_{20}-BPh_4^-]$, has been misidentified. As prepared, the cation is a hydride-bridged silane adduct $[R_3Si-H-SiR_3^+]$. Under favorable circumstances it can be an effective source of the triethylsilylium ion Et₃Si⁺, but in the absence of a stabilizing base the potent electrophilicity of Et₃Si⁺ decomposes the "inert" F₂₀-BPh₄⁻ counterion.

ver the past decade, R₃Si⁺ silylium ion chemistry has progressed from controversy over their existence 1-6 to an exploitation of their potent electrophilicity in stoichiometric reactions⁷ and, most impressively, in catalytic chemistry.⁸ These advances owe much to the availability of very weakly coordinating anions, 9,10 particularly carborane anions 7 and the perfluorinated tetraphenylborate anion¹¹ (abbreviated F_{20} -BPh₄⁻ or PFTPB⁻).

A frequently used reagent in this silylation chemistry is the socalled triethylsilyl perfluorotetraphenylborate salt $[Et_3Si^+][F_{20}-BPh_4^-]$, first reported by Lambert.^{12,13} It is a versatile reagent for the abstraction of halide ions from transition metal complexes and from main group element compounds to give reactive, coordinatively unsaturated cations with F_{20} -BPh₄⁻ counterions. As liquid clathrates or "swirls", such salts have high effective solubilities in low dielectric solvents, making them very suitable for cationic catalysis. The reagent is readily prepared by reaction of the trityl salt of the F_{20} -BPh₄⁻ anion with triethylsilane, both starting materials being commercially available (eq 1).

$$Et_{3}SiH + [Ph_{3}C^{+}][PFTPB^{-}] \rightarrow [Et_{3}Si^{+}][PFTPB^{-}] + Ph_{3}CH$$
(1)

Given that all solvents, even those as weakly coordinating as benzene,¹³ dichlorobenzene, and liquid SO₂,¹⁴ coordinate to the Et_3Si^+ ion forming $[Et_3Si(solvent)]^+$ cations, $[Et_3Si^+][F_{20}-BPh_4^-]$ was prepared in the "absence" of solvent, or more correctly, using excess triethylsilane reagent as solvent.¹³ Evaporation of the excess silane gave a white powder, which was characterized by CPMAS NMR as $[Et_3Si^+][F_{20}-BPh_4^-]$. The lack of any detectable difference in the ¹⁹F NMR of the anion between the presumed [Et₃Si⁺][F₂₀-BPh₄⁻] and the corresponding trityl ion salt of F_{20} -BPh₄⁻ led to the conclusion that the F_{20} -BPh₄⁻ anion was not coordinated to silicon.¹³ Lending some support to this ionic formulation is the more recent report of the X-ray crystal structure of the Me₃Si⁺ moiety partnered with the most



Figure 1. ATR IR spectra of $[Et_3Si-H-SiEt_3]^+Y^-$ for $Y = F_{20}-BPh_4^-$ (red) and CHB₁₁Cl11⁻ (black) showing the distinctive v_{as} SiHSi band near 1900 cm⁻¹

weakly coordinating carborane anion, the undeca-fluorinated $RCB_{11}F_{11}^{-}$ ion.¹⁵ The sum of the three C-Si-C angles in the Me₃Si moiety in Me₃Si(RCB₁₁ F_{11}) is 354.4°, only ca. 6° short of the planarity expected for a Me₃Si⁺ ion. The Si atom is 0.25 Å out of the plane of the three C atoms toward the carborane anion. While perhaps not strictly ionic, this compound is certainly ion-like.

However, during routine characterization of the presumed $[Et_3Si^+][F_{20}-BPh_4^-]$ salt we noticed that its ATR-IR spectrum contained an unanticipated strong absorption at ca. 1900 cm^{-1} . We had noticed this band earlier while characterizing the hydridebridged disilyl cation [Et₃Si-H-SiEt₃]⁺ as a CHB₁₁Cl₁₁⁻ carborane salt and assigned it to $\nu_{\rm as}$ SiHSi.¹⁴ Even the distinctive shape of the band was reproduced (see Figure 1). It is immediately evident that the so-called silvlium ion salt [Et₃Si⁺][F₂₀-BPh₄⁻] is, in fact,

Received: July 14, 2011 Published: August 19, 2011 isolated as a silane adduct thereof: $[Et_3Si-H-SiEt_3][F_{20}-BPh_4]$. Once again, the solvent is coordinated to the silylium ion (eq 2).

$$2Et_{3}SiH + Ph_{3}C[F_{20} - BPh_{4}] \rightarrow [Et_{3}Si-H-SiEt_{3}][F_{20} - BPh_{4}]$$
$$+ Ph_{3}CH$$
(2)

The same result is obtained whether pure silane or a silane/ hexane mixture is used as solvent, as long as at least 2 equiv of silane are present. When the formation reaction is carried out with only 1 equiv of Et₃SiH, ¹H NMR indicates that only half of the trityl ion is consumed. The reaction appears to be general. When trimethyland triisopropylsilane are substituted for triethylsilane, the products have the same characteristic IR band of a $[R_3Si-H-SiR_3]^+$ cation (see Supporting Information). The products have the correct elemental analyses for $[R_3Si-H-SiR_3][F_{20}$ -BPh₄] salts. In addition, the presence of a displaceable equivalent of volatile silane was established by ¹H NMR for the isolated triethylsilane product by dissolving it in benzene and integrating $[Et_3Si(benzene)]^+$ against a hexamethylbenzene internal standard.

This finding offers a note of caution to those using so-called " $[Et_3Si][F_{20}-BPh_4]$ " in synthesis.^{16–33} When prepared using excess silane as the sole solvent (or when using excess silane mixed with a noncoordinating solvent for the Et_3Si^+ ion, e.g., an alkane), the isolated product will be $[Et_3Si-H-SiEt_3][F_{20}-BPh_4]$ not $[Et_3Si][F_{20}-BPh_4]$. Because of its higher molecular weight, stoichiometries in subsequent metathesis reactions may therefore be miscalculated. Fortunately, the "extra" equivalent of silane is usually displaced during a silylation reaction and escapes the reaction as an innocent volatile byproduct. Indeed, those^{22–33} who predissolve $[Et_3Si-H-SiEt_3][F_{20}-BPh_4]$ in a solvent that is coordinating to the Et_3Si^+ ion, e.g., arenes and ethers, will displace the silane, forming $R_3Si(solvent)^+$ cations as the active silylating agents. Silane may be seen bubbling off.

These observations beg the question, "does [Et₃Si][F₂₀-BPh₄] really exist?" The answer appears to be no. When a film of [Et₃Si-H-SiEt₃][F₂₀-BPh₄] is deposited on the windows of an evacuable IR cell and pumped at 10⁻⁶ Torr for 6 h, no loss of intensity of the ν_{as} SiHSi band is observed; that is, silane is not removed from the [Et₃Si-H-SiEt₃]⁺ cation under high vacuum at room temperature. When heated under vacuum to 65 °C, the colorless product turns black and tris(pentafluorophenyl)boron³⁴ is an identifiable sublimate. The cleavage of a pentafluorophenyl group from the F₂₀-BPh₄⁻ anion is consistent with a growing number of reports that this anion is unstable toward strong electrophiles including H^{+,35} "naked" Ag^{+,36} and R₃Si^{+,17} Nevertheless, there is one report of [Me₃Si][F₂₀-BPh₄] as a colorless solid with mp 137 °C, no IR band in the region expected for ν_{as} SiHSi, and an acceptable C,H elemental analysis.³⁷ When we repeated the described synthetic procedure, we observed only the formation of [Me₃Si-H-SiMe₃][F₂₀-BPh₄].³⁸

In summary, there is no evidence for the existence of $[Et_3Si][F_{20}\text{-}BPh_4]$. The "as prepared" material is the silane adduct $[Et_3Si-H-SiEt_3][F_{20}\text{-}BPh_4]$, and our attempts to remove the silane under vacuum led to decomposition of the F_{20} -BPh₄⁻ anion. Only halogenated carborane anions are stable to the fierce electrophilicity of the Et_3Si^+ silylium ion.^{7,15,39} A truly free trialkylsilylium ion exists only in the gas phase.

ASSOCIATED CONTENT

Supporting Information. Synthetic details and spectra. This material is available free of charge via the Internet at http://pubs.acs.org.

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ACKNOWLEDGMENT

This work was supported by the National Science Foundation (CHE 0841428) and the National Institutes of Health (ARRA 3RO1GM023851-30S1).

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